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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Toshio SAKURAI et al.

Group Art Unit: 2812

Application No.: 10/564,393

Examiner: R. PATEL

Filed: May 8, 2006

Docket No.: 126617

For: LOW DIELECTRIC CONSTANT FILMS AND MANUFACTURING METHOD
THEREOF, AS WELL AS ELECTRONIC PARTS USING THE SAME

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the March 24, 2009 Restriction Requirement, Applicants provisionally elect Group V, claims 12 through 18, with traverse.

It is also respectfully submitted that the subject matter of all claims is sufficiently related that a thorough search for the subject matter of any one Group of claims would encompass a search for the subject matter of the remaining claims. Thus, it is respectfully submitted that the search and examination of the entire application could be made without serious burden. See MPEP §803 in which it is stated that "if the search and examination of an entire application can be made without serious burden, the examiner must examine it on the merits, even though it includes claims to independent or distinct inventions" (emphasis added). It is respectfully submitted that this policy should apply in the present application in order to avoid unnecessary delay and expense to Applicants and duplicative examination by the Patent Office.

Thus, withdrawal of the Restriction Requirement is respectfully requested.

Respectfully submitted,



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Date: April 8, 2009

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